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Flip Chip Underfill

Low Moisture Absorption Low Ionic Impurities High Temperature Stability Low CTE

IDEAL FOR:

Flip-chip underfill
Ultra-high temperature encapsulation
Applicable for Flip Chip Underfill with < 20Micron Bumps

DESCRIPTION:

UF-MC7885-FP is a one part, filled modified cyanate ester flip-chip underfill and has less than 10 micron particle size compared tp UF-MC7883-FP. It is designed for use in both chip-on-board underfill and standard flip-chip underfill component application to reduce stress. It can withstand temperatures up to 350°C without thermal degradation. Its unique chemistry results in very low moisture absorption, high strength protection.

UF-MC7885-FP is designed to be dispensed on the edge of flip-chip die for capillary pull-in to fill in the gap before curing. The cured underfill has less than 20 ppm/C in coefficient of thermal expansion and higher than 6 Gpa in modulus.

AVAILABILITY:

UF-MC7885-FP is available in syringes for automatic dispense applications.

APPLICATION PROCEDURES:

- (1) Thaw to room temperature before opening container.
- (2) Dispense underfill onto the adjacent edges of die a suitable pattern to assure full die coverage.
- (3) Cure according to the recommended schedule, i.e. B-Stage followed by a cure schedule.

NOTE: The monomer contained in this product is subject to crystallization even at room temperature. If product is thawed and remains crystallized, simply place in 40 C environment for as long as needed to return product to the liquid state i.e. usually not more that 15 - 20 minutes.

FLIP-CHIP UNDERFILL UF-MC7885-FP

TYPICAL PROPERTIES*

Electrical Resistivity >1X10 ¹⁴ ohm-cm

NA °C/

Dielectric Strength (Volts/mil) >750

Glass Transition Temp.(°C) 240 ±10%

Lap-Shear Strength >1000 psi

>6.9 N/mm²

Device Push-off Strength >2000 psi

>2000 psi >13.8 N/mm²

Hardness (Type) 80 (D) ±10%

Cured Density (am/cc) 2.2 ±10%

Thermal Conductivity >9.3 Btu-in/hr-ft²-of ±10%

>1.5 W/m-°C ±10%

Linear Thermal Expansion 18 ±15%

Coeff. (ppm/°C)

Maximum Continuous Operation Temp. (°C) <300

Avg. Viscosity(5.0 rpm, 25°C) 10,000 cp (Brookfield DV-1,spindle CP51)

CURE SCHEDULES:

Temperature Time Pressure

60-80°C 5 min Underfilling & follow by

100°C 120min 125°C 60min

Post cure can be done using 10 degrees C higher than operation temperature for 10 minutes

SHELF LIFE:

Storage temperature
-40°C
Shelf Life

<u>CAUTION:</u> This product may cause skin irritation. Avoid skin contact. If contact does occur, wash immediately with soap and water. Please refer SDS for more details. The information contained herein is believed to be reliable. All recommendations or suggestions are made without guarantee inasmuch as conditions and methods of commercial use are beyond our control. Properties given are typical values and not intended for use in preparing specifications. The user is advised to evaluate the product in the manner the product is to be used in manufacturing and in the final product. Under no circumstance shall Al Technology be liable for accidental, consequential or other damages arising from the use or

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